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PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No.

10/087,510

Applicants

SETHURAMAN JAYASHANKAR ET AL

Filed

March 1, 2002

Title

SINGLE LAYER RESIST LIFT-OFF

PROCESS AND APPARATUS FOR

SUBMICRON STRUCTURES

Group Art Unit

1765

Examiner

Shamim Ahmed

Docket No.

011333

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, Virginia 22313-1450

on

ELECTION AND AMENDMENT

this 28 II day of October, 2003.
Bea Nac Donelo

Buchanan Ingersoll, P.C.

Pittsburgh, Pennsylvania 15219

October 28, 2003

Commissioner for Patents Post Office Box 1450 Alexandria, Virginia 22313-1450

Sir:

In response to Office Action dated September 30, 2003, please amend this application as set forth hereinafter.

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begins on page 7 of this paper.